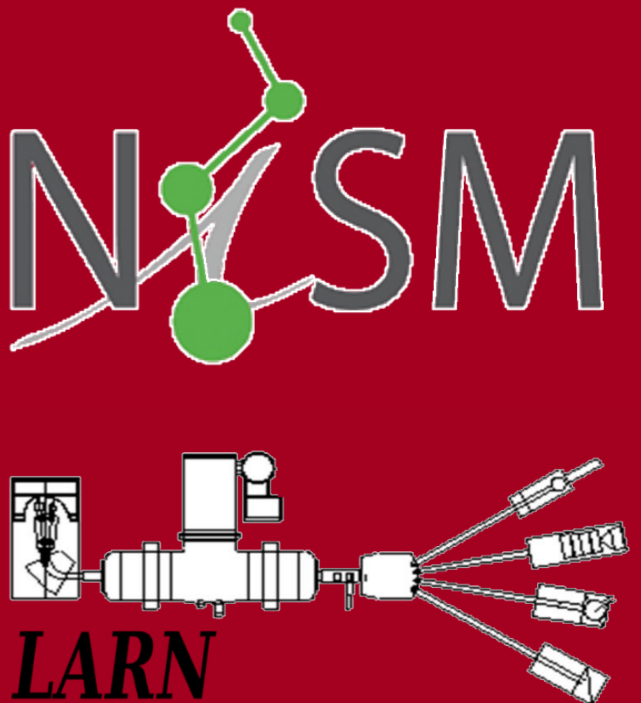
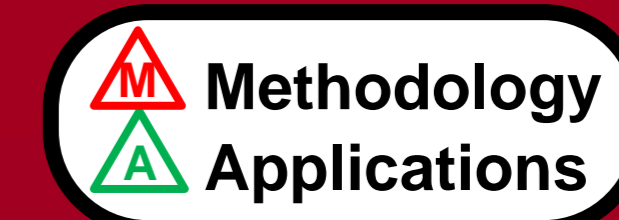




Multi-scale modelling of TCO coating deposited by reactive magnetron sputtering: application to structured c-Si thin film solar cells



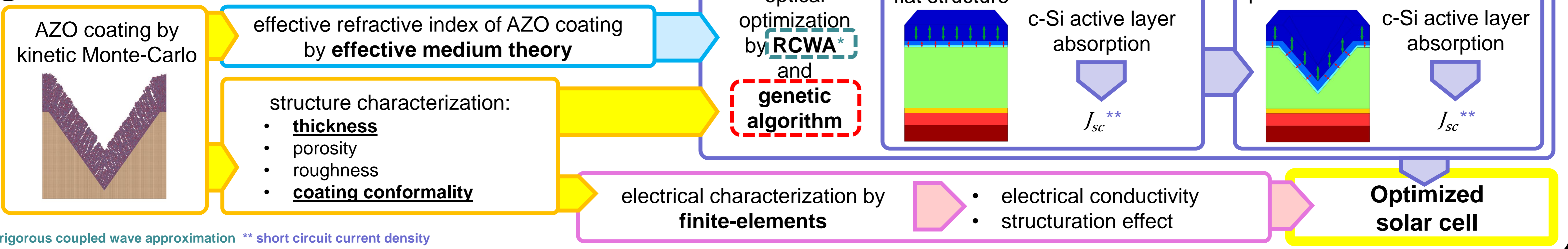
Jérôme Müller, Pavel Moskovkin, Alexandre Mayer, Olivier Deparis, Stéphane Lucas
LARN, PMR, Namur Institute of Structured Matter (NISM)
University of Namur (UNAMUR), BELGIUM



Introduction: Transparent conductive oxides (TCO) present a large range of applications such as optoelectronic devices, especially transparent front-side contact for solar cells. In this last case, aluminum doped zinc oxide (ZnO:Al or AZO) can be a good alternative to indium tin oxide (ITO). Our work focuses on a full characterization process of crystalline silicon thin film solar cells structured by periodic inverted pyramids (wet etching). Such characterization is based on ① AZO film growth modelling by kinetic Monte-Carlo, ② effective electrical properties and ③ optical properties of the AZO coating (respectively by finite-elements and effective medium theory). Finally, ④ a full optimization by genetic algorithm, coupled to the RCWA optical tool, is done on the full multi-layered patterned solar cell.



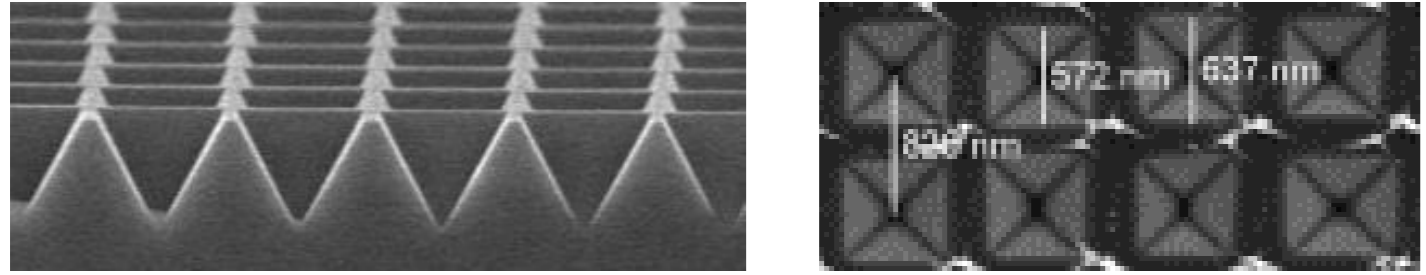
① Solar cell modelling and optimization: flowchart



* rigorous coupled wave approximation ** short circuit current density

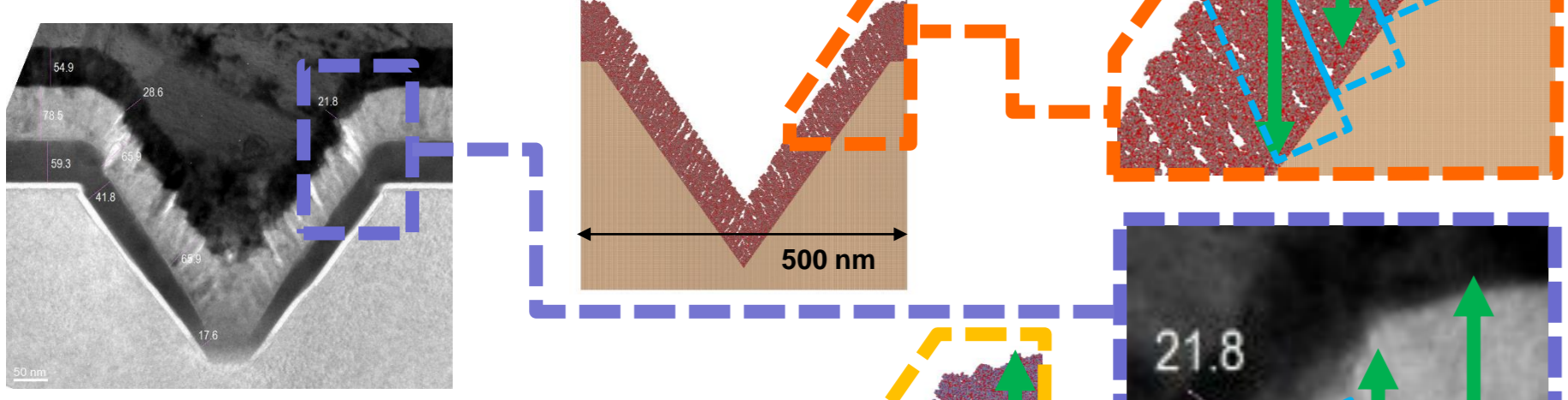
1 AZO film growth modelling

- deposition by reactive sputtering on **inverted pyramids*** (wet etched c-Si)

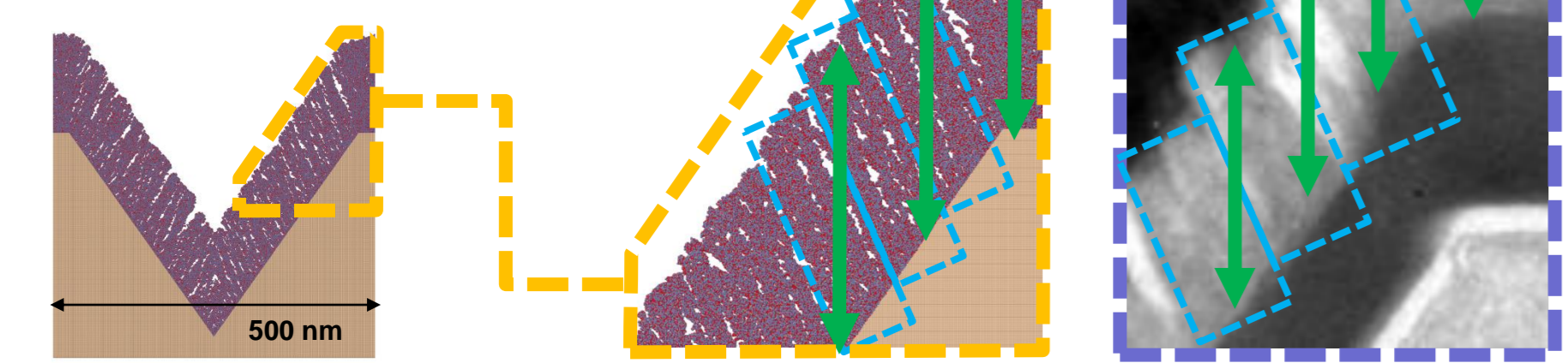


- modelling by **kinetic Monte-Carlo**** (NASCAM software)

- validation: ITO coating



- AZO coating**



- thickness constant in the vertical direction
- higher porosity in the tilted zone

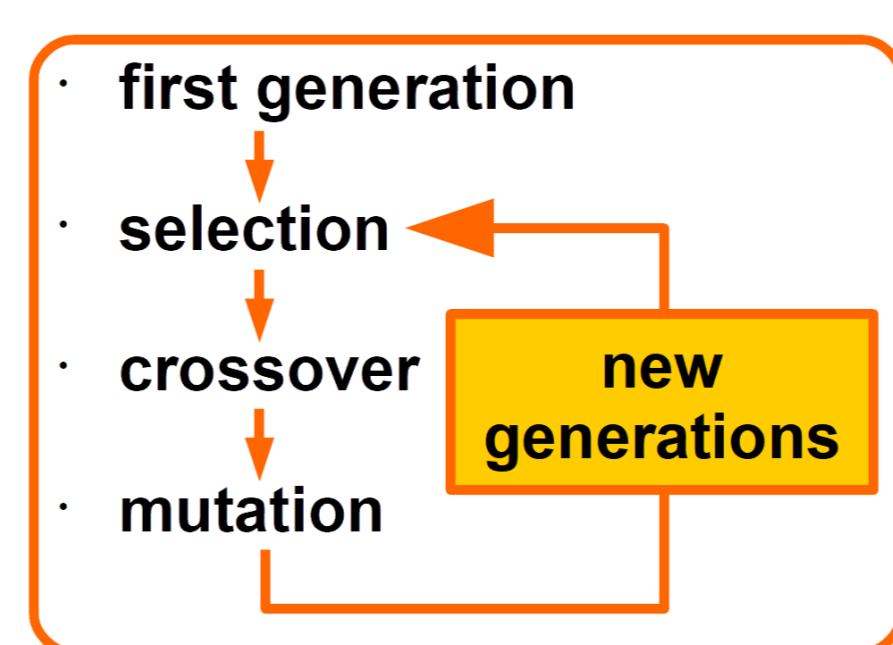
* V. Depauw and al., *Nanophotonics for ultra-thin crystalline silicon photovoltaics: when photons meet electrons*, Proceedings of EU PVSEC, p. 1461 - 1469 (2014).

** R. Tonneau and al., *TiO_x deposited by magnetron sputtering: a joint modelling and experimental study*, Journal of Physics D: Applied Physics, 51 (2018) 195202 (17pp).

*** Neng-Fu Shih and al., *Properties and Analysis of Transparency Conducting AZO Films by Using DC Power and RF Power Simultaneous Magnetron Sputtering*, Advances in Materials Science and Engineering, vol. 2013, Article ID 401392, 6 pages, 2013.

Tool Genetic Algorithm*

- optimization algorithm inspired by the natural selection process
- powerful tool for optimization of a large number of parameters (≥3)

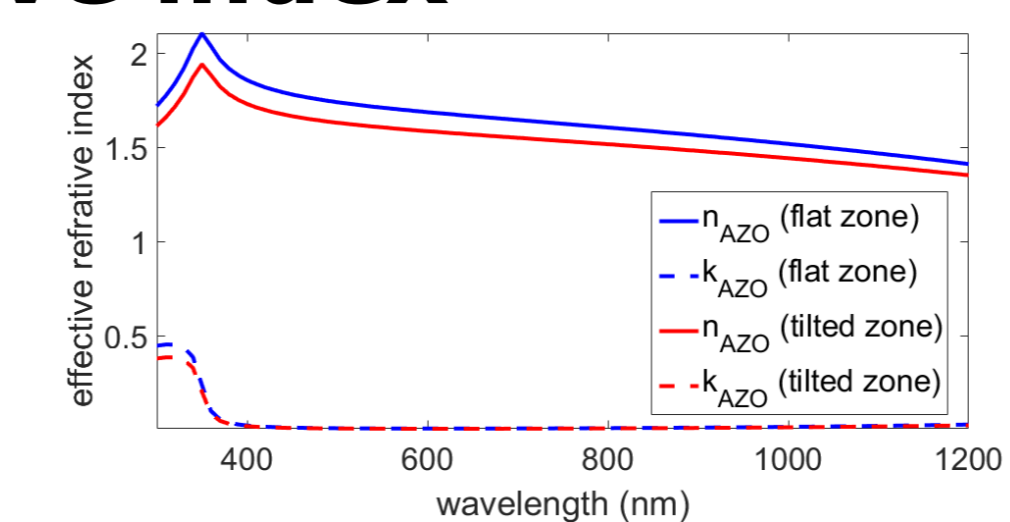


* A. Mayer and M. Lobet, *UV to near-infrared broadband pyramidal absorbers via a genetic algorithm optimization approach*, Proceedings of SPIE, vol. 10671, p.1067127 (2018).

3 AZO effective refractive index

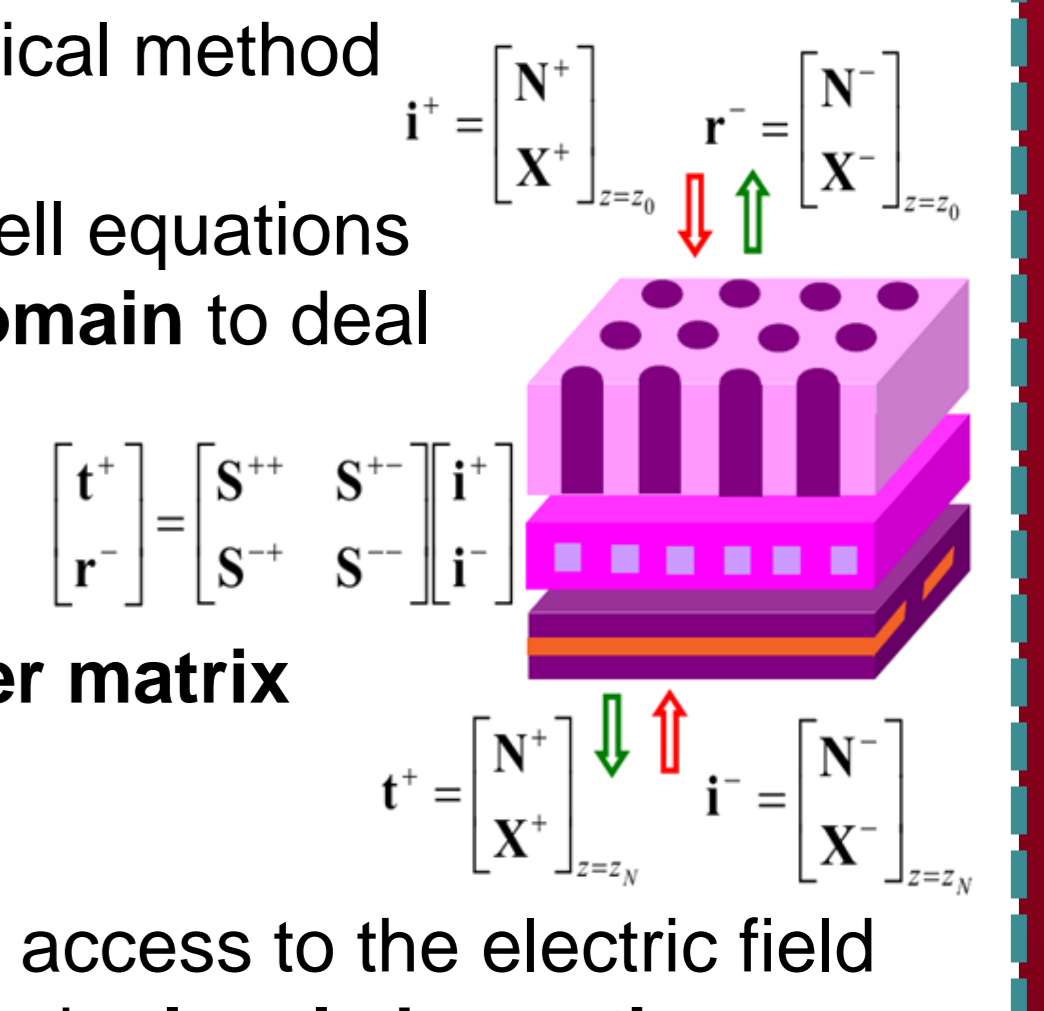
- effective medium theory based on Maxwell-Garnett method:

$$\frac{\epsilon_{eff} - \epsilon_h}{\epsilon_{eff} + \gamma\epsilon_h} = \sum_{i=1}^{n-1} f_i \frac{\epsilon_i - \epsilon_h}{\epsilon_i + \gamma\epsilon_h}$$



Tool Rigorous Coupled Wave Approx.*

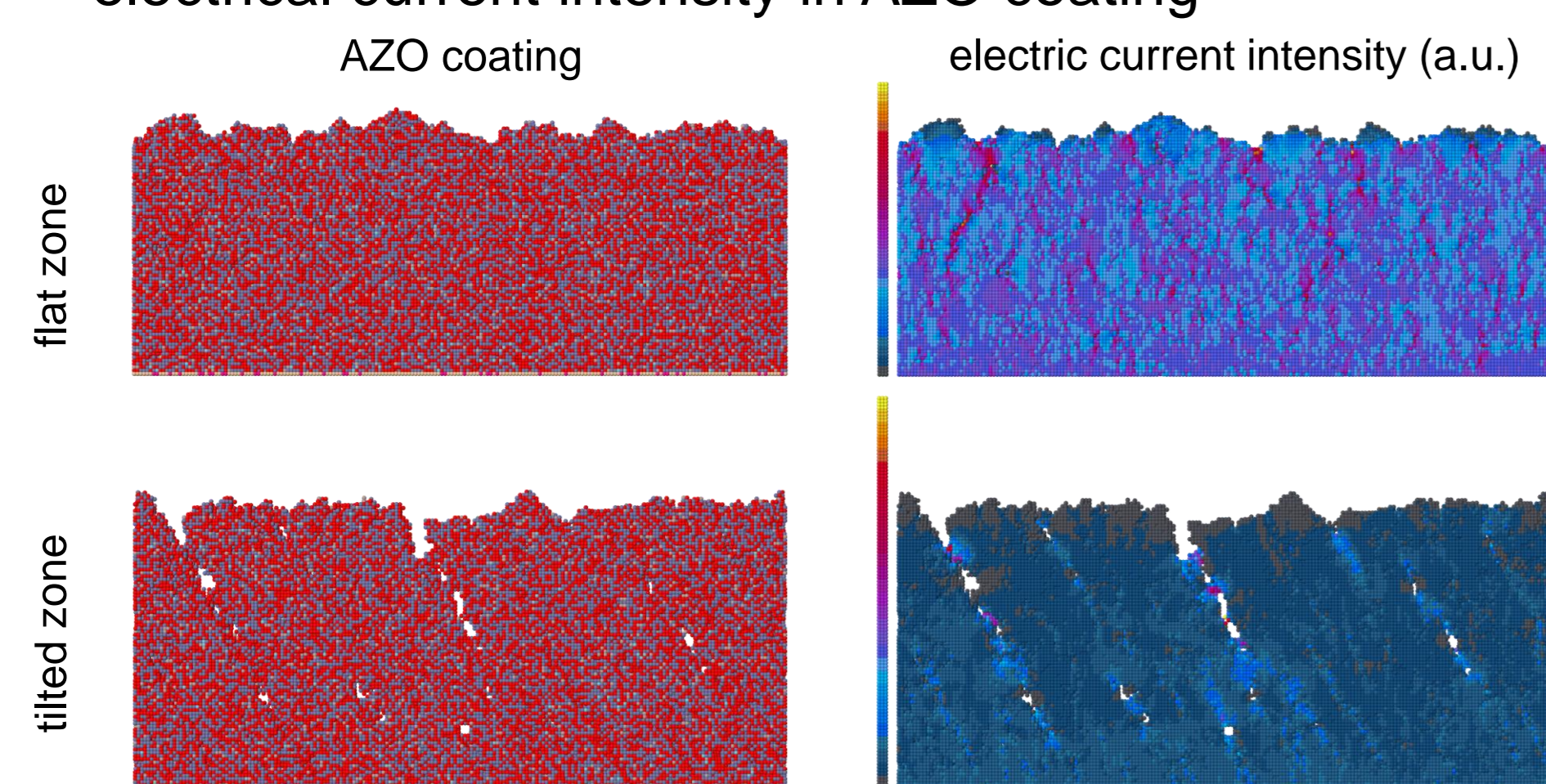
- semi-analytic optical method
- solves the Maxwell equations in the **Fourier domain** to deal with **periodic structures**
- based on **transfer matrix** computation
- possible to have access to the electric field maps and then to the **local absorption**



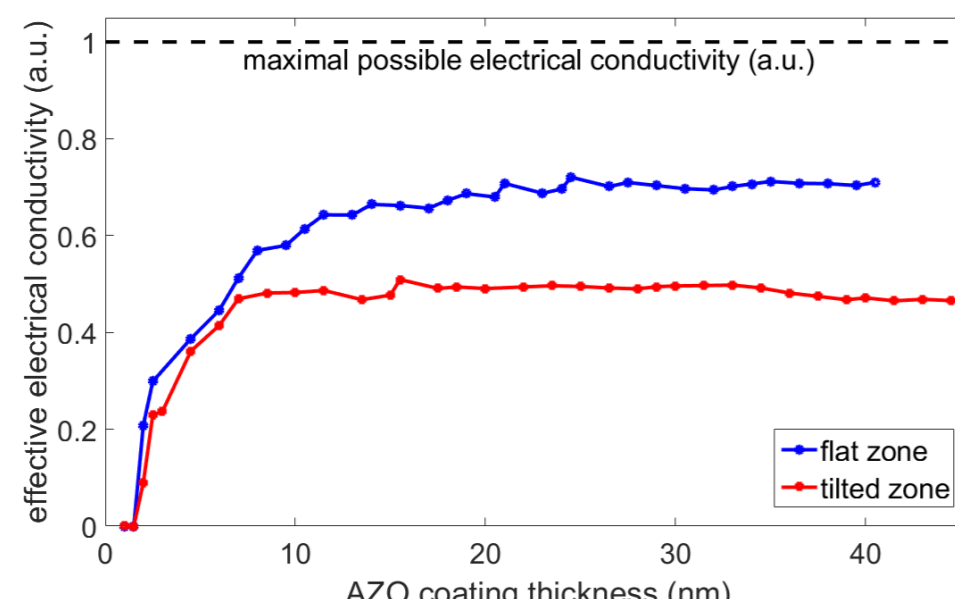
* J. Müller and al., *A fair comparison between ultrathin crystalline-silicon solar cells with either periodic or correlated disorder inverted pyramid textures*, Opt Express 2015 Jun 1;23(11):A657-70.

2 Electrical characterization

- finite-elements model
 - solve the Maxwell-Faraday equation (hypothesis: near-absence of varying magnetic field)
 - compute the voltage field in the whole structure allowing a minimal dissipated power
- electrical current intensity in AZO coating



- effective conductivity
 - high impact of the porosity in the tilted zone
 - no evolution after 15nm



note about the a.u.: 1 represents the conductivity of a perfectly dense coating

4 Optical optimization

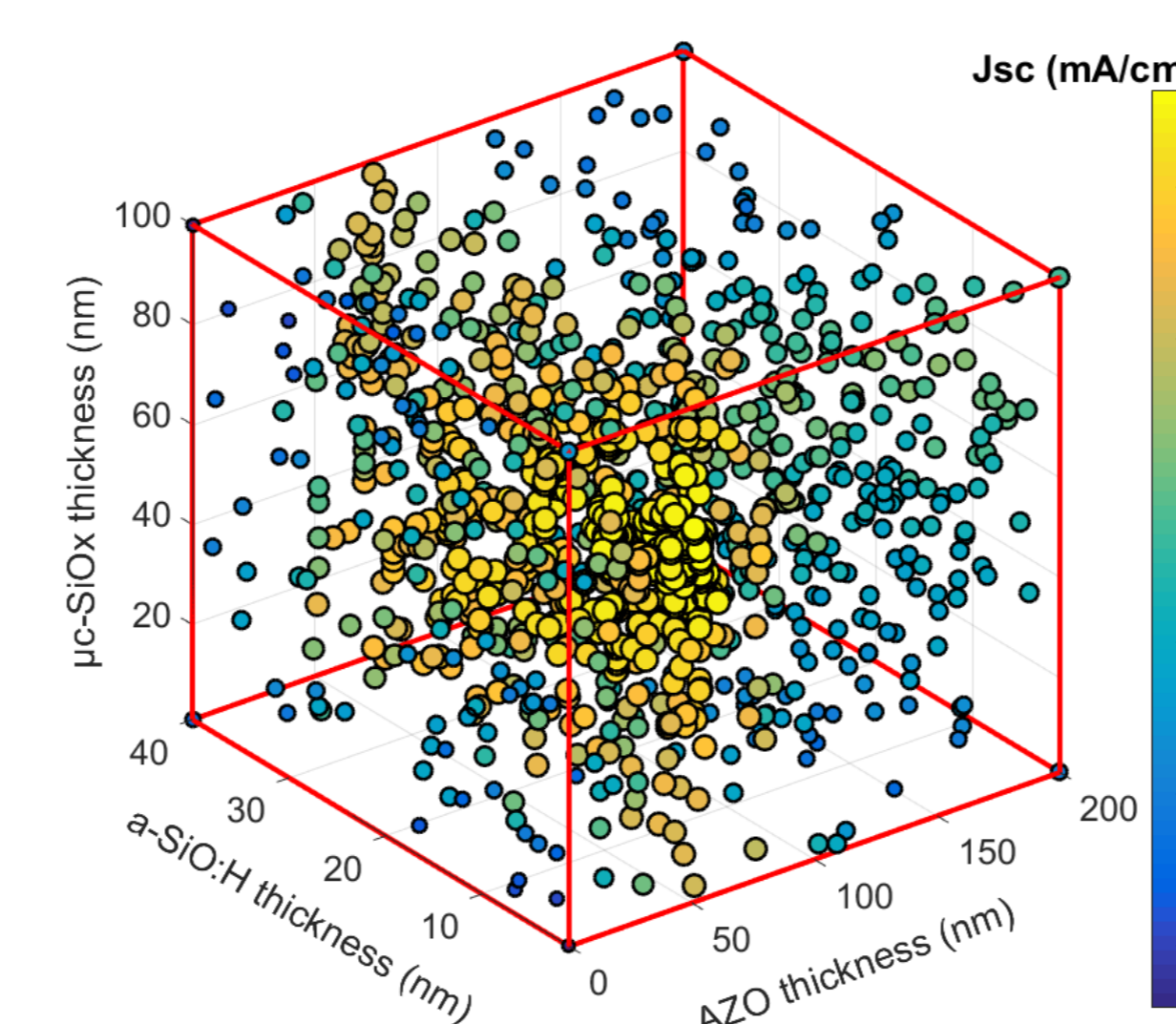
- computation for absorbance spectrum in the active layer (A_{cSi})
- computation of the **short circuit current**:

$$J_{sc} = \frac{e}{h c} \int_{300nm}^{1200nm} \lambda S(\lambda) A_{cSi}(\lambda) d\lambda$$

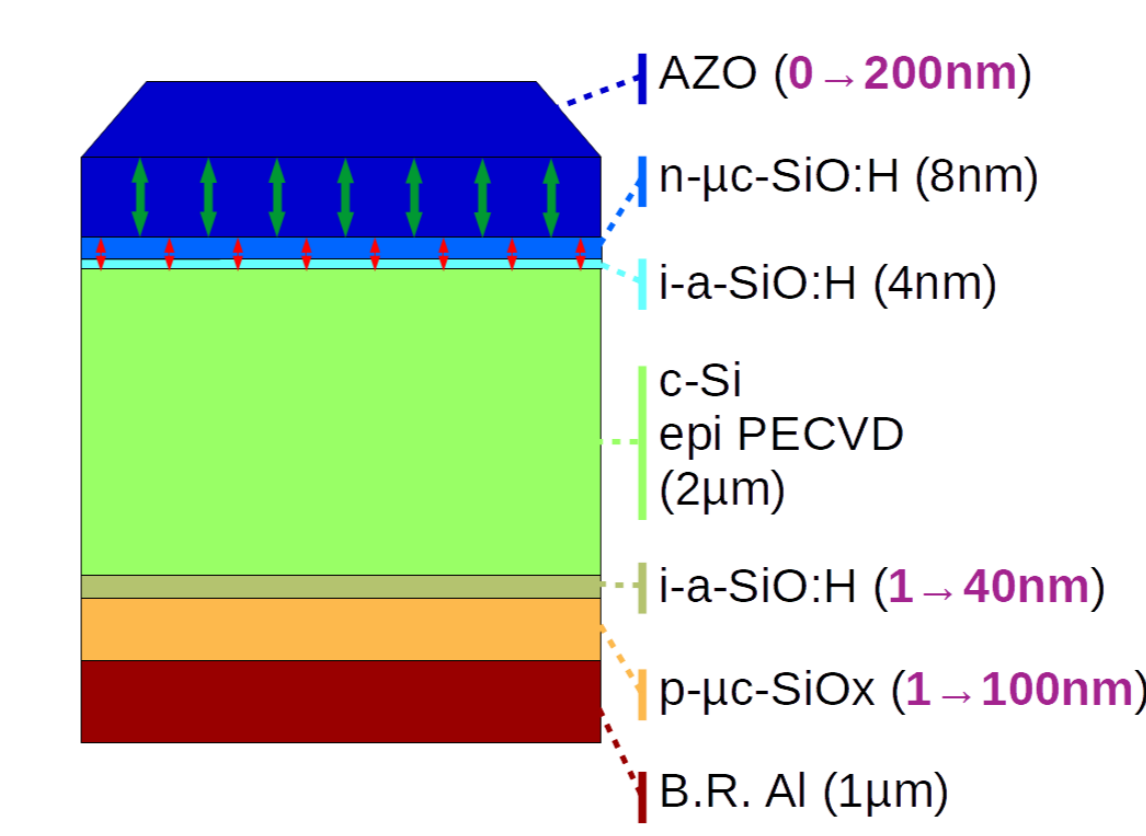
- optimization by **genetic algorithm**

* with e the electron charge, h the Planck constant, c the light speed, λ the wavelength, S the reference solar spectral irradiance, A_{cSi} the absorption in the cSi layer computed by RCWA.

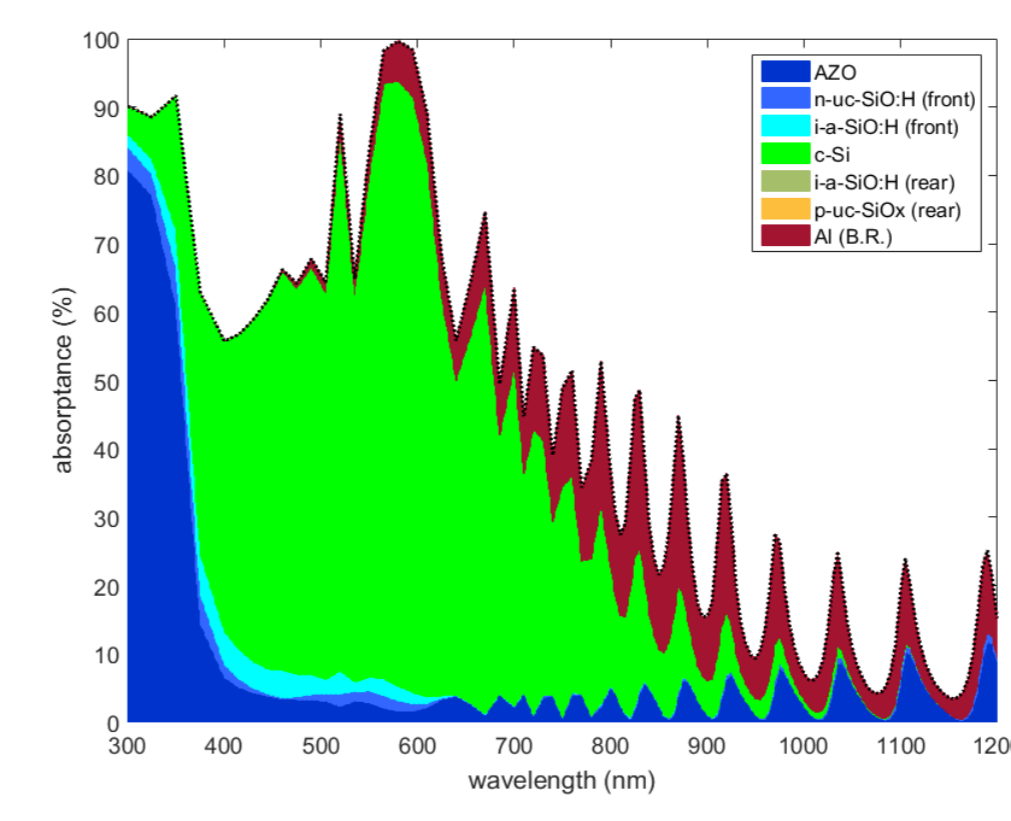
- J_{sc} for all parameters investigated by the genetic algorithm



optimization of the flat stack



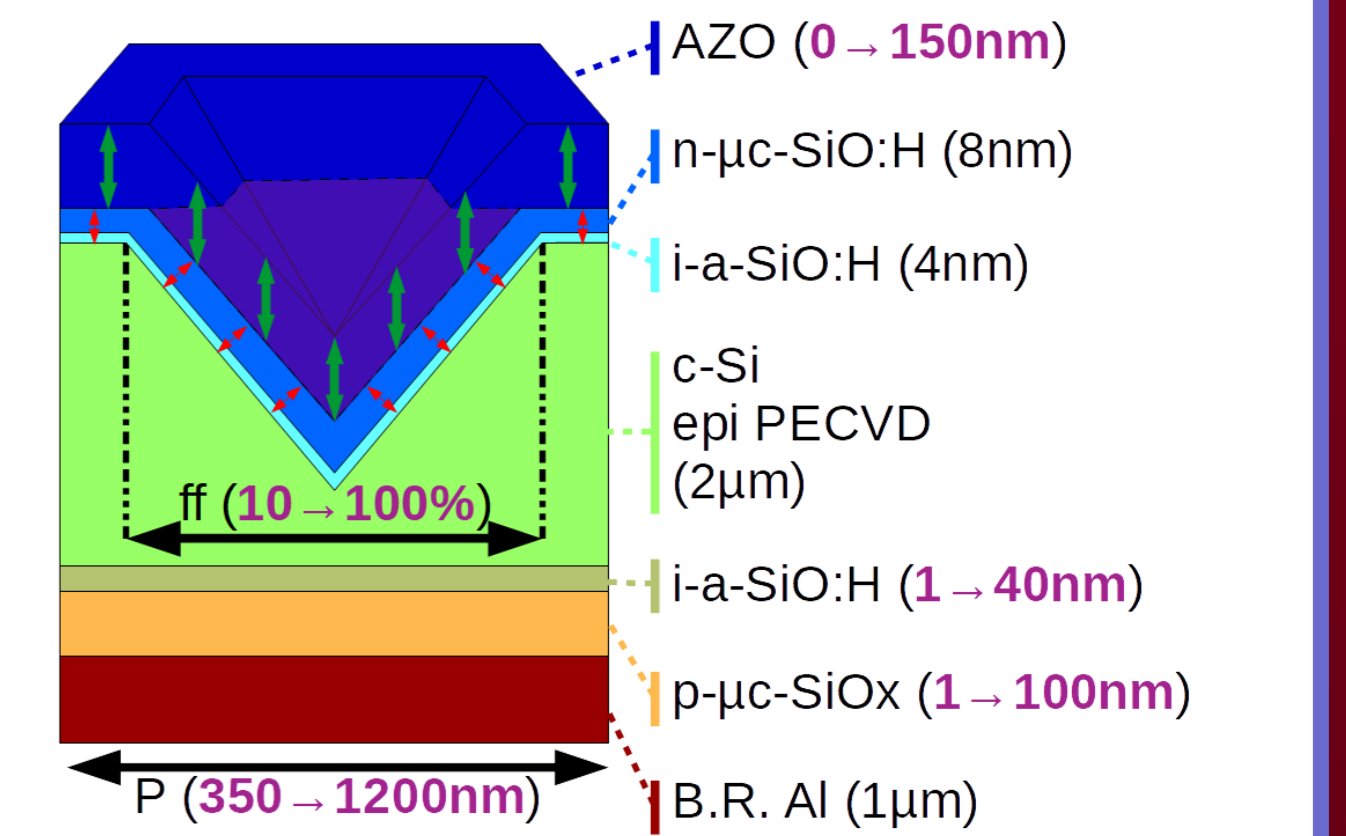
- absorbance spectra of each layer



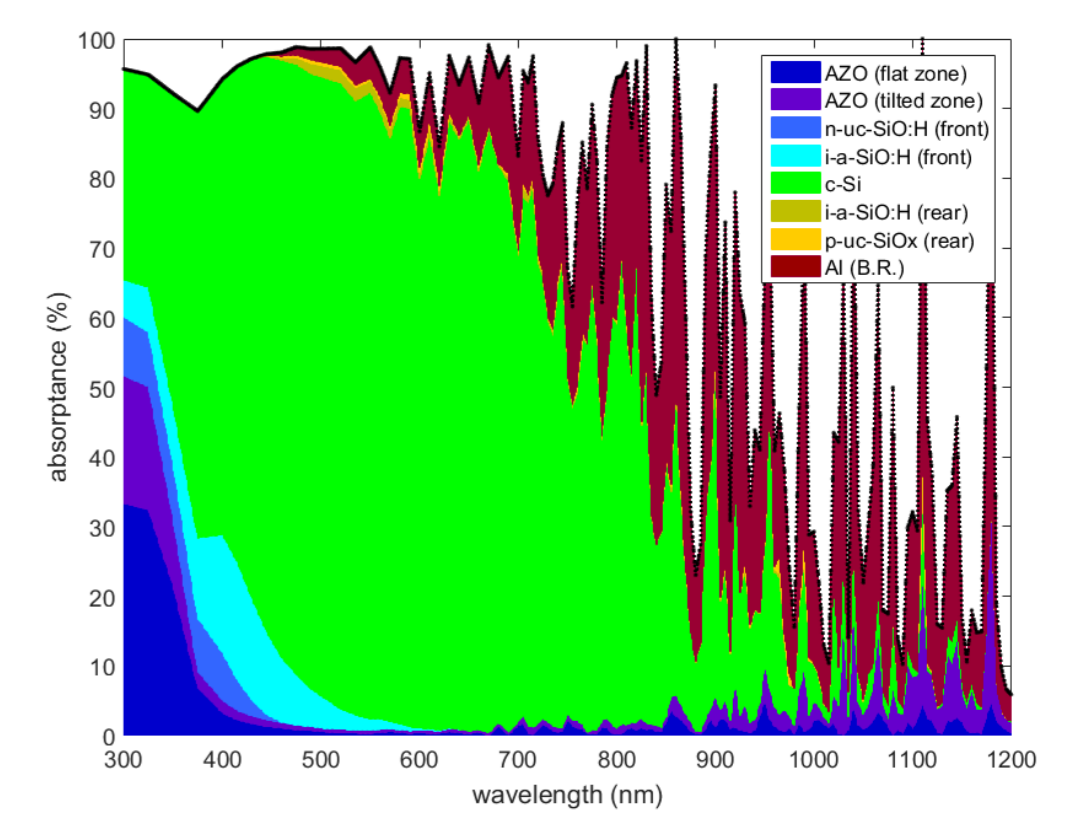
- optimal short circuit current:

$$J_{sc} = 17.6 \text{ mA/cm}^2$$

optimization the patterned stack



- absorbance spectra of each layer



- optimal short circuit current:

$$J_{sc} = 24.3 \text{ mA/cm}^2$$

Conclusion: In this work based on the numerical modelling of atomistic deposition by reactive sputtering of AZO on a structured substrate, a full characterization process was performed to estimate the electrical and optical properties of a crystalline silicon solar cell using this AZO coating as a front transparent conductive oxide. Such study pointed the high impact of the substrate pattern on those physical properties, especially the decrease of the electrical conductivity. Moreover, a global optimization by genetic algorithm was used to enhance the efficiency of such multi-layered structured solar cells.